### Molecular dynamics study on radiation hardening and fracture processes in FCC metals

### Hideo Kaburaki (JAERI)

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### **Effect of external shear stress for unfaulting**



### **Unfaulting process of H721 vacancy loop**

#### **Partial dislocation loop**



Central symmetry parameter representation



### **Stacking fault**

### **Results of unfaulting critical shear stress**

### for vacancy loops



## Hardening process --- the interaction of an edge dislocation with a hexagonal interstitial dislocation loop



200 Å Number of atoms  $3.8 \times 10^5$ 

Interatomic potential : Embedded-atom method (EAM) potential **Cu, Al** [Y. Mishin *et al.*, *PRB* (2001).]  $E_{tot} = \frac{1}{2} \sum_{ij} V(r_{ij}) + \sum_{i} F(\overline{\rho}_{i})$  *V*: Pair potential *F*: Embedding energy

## Pinning structure formed due to the interaction of an edge dislocation and an interstitial cluster in **Cu**



**H007** 







## Pinning structure formed due to the interaction of an edge dislocation and an interstitial cluster in Al



H007

#### H037

#### H169

H721

### A molecular dynamics study on displacement cascades in the strain field of an edge dislocation in Cu







### Temperature dependence on the crack-tip dislocation nanostructures (Cu)





0 K

### Disl. motion on the slip plane (Cu, 50K)



16 ps



**20 ps** 

22 ps



24 ps

# **Expansion and emission process of stacking-fault loops**



